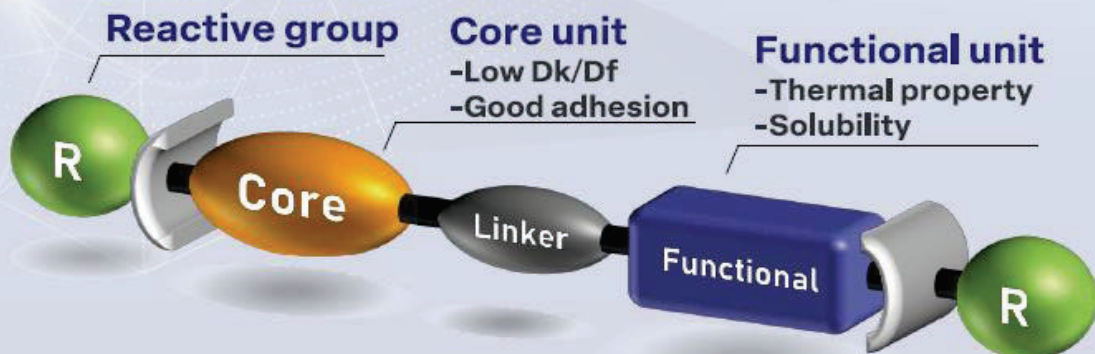


JSR ELPAC™ HC-G series

Low Dk/Df **STPE** (Self-crosslinking Thermosetting PolyEther)

Design Concept

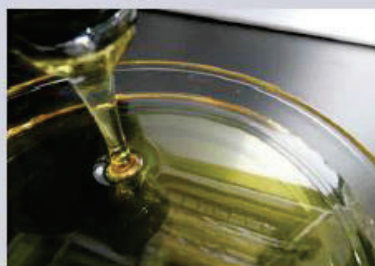
-Good balance between Dk/Df and other properties such as adhesion, thermal property, and solubility



Products list

Products	HC-G0037	HC-G0024	HC-G0030	HC-G0038
Core + Functional	A	B	C	D
R	Radical-curable			
Non-volatile (%)	62	62	40	50
Viscosity (mPa • s)	500-1,500	1,500-2,500	15-20	50-150
Solvent	Toluene			

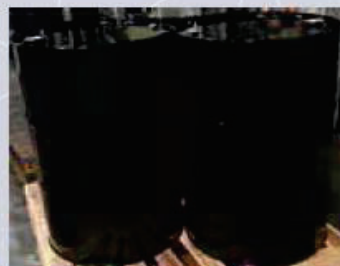
Appearance



Product container



20L
Pail



200L
Drum

(with HDPE liner)

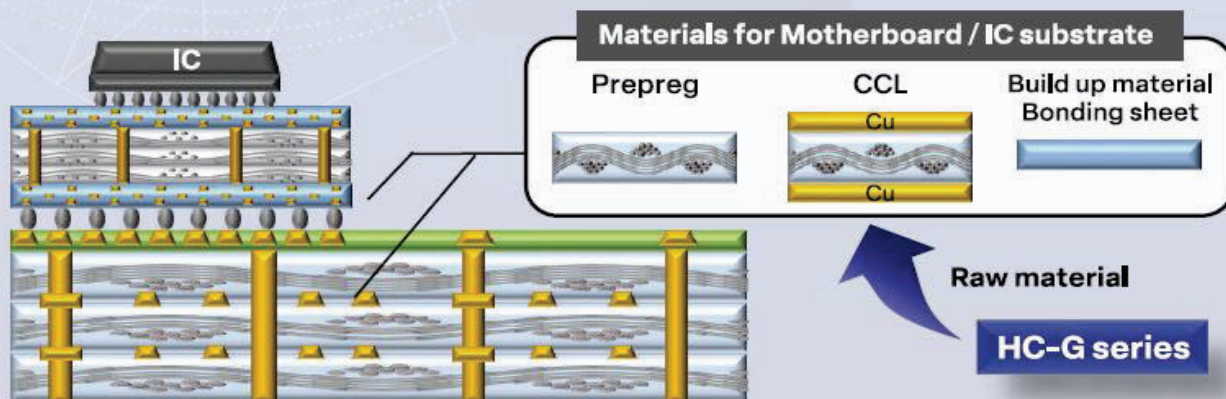
JSR ELPAC™ HC-G series

Low Dk/Df **STPE** (Self-crosslinking **T**hermosetting **P**oly**E**ther)

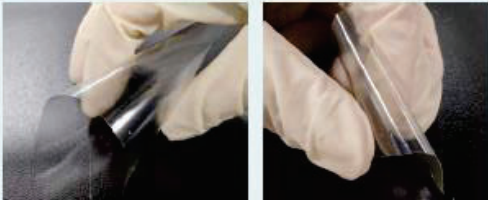
Application

-Expected to be useful as a raw material for circuit board

- ✓ High speed communication for Data Center/AI
- ✓ High Frequency for Antenna, Radar, Sensor and etc.
- ✓ Low Dk/Df IC substrate



Evaluation examples as cured film

	HC-G0037	HC-G0024	HC-G0030	HC-G0038
Feature	Low Df Good adhesion	Low Df High Tg	Low Df Good adhesion	Low Df High Tg
Dk (10GHz)	2.6	2.6	2.6	2.6
Df (10GHz)	0.0011	0.0009	0.0011	0.0014
Tg (°C, DMA)	172	233	176	184
T _d ⁵ (°C)	390	399	396	395
Peel strength with Cu (N/mm)	0.8	0.6	0.8	0.7
Appearance			-	-

Composition: HC-G polymer / Organic peroxide. Cured at 200 °C

Feb. 2025

JSR ELPAC™ HC-G series

Low Dk/Df **STPE** (Self-crosslinking Thermosetting PolyEther)

Evaluation examples as CCL

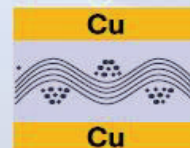
Glass cloth
Nittobo NEZ™ #1078

**Impregnation
Drying**



Vacuum press

200 °C

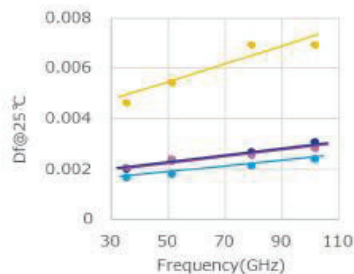
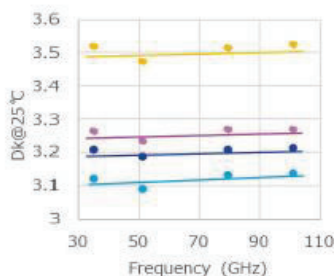


	HC-G0037 CCL	HC-G0024 CCL
Dk (10GHz)	3.2	2.8
Df (10GHz)	0.0013	0.0010
Tg (DMA)	183 °C	197 °C
Peel strength ¹⁾	0.9 N/mm	0.5 N/mm
Solder test @300°C	>300 sec	>300 sec



Composition: HC-G0037/PPE/Silica/SEBS/Flame retardants/Organic peroxide
Composition: HC-G0024/Silica/LDM-03/SEBS/Flame retardants/Organic peroxide
1) H-VLP3 Copper foil : Rz=0.5 μm

Frequency dependence of Dk/Df



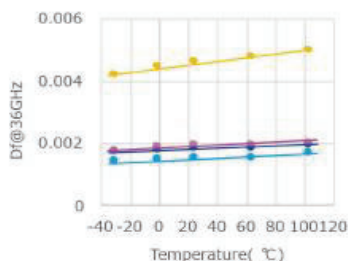
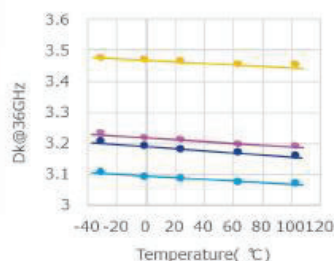
HC-G0037 CCL

HC-G0024 CCL

Commercially available CCL-1

Commercially available CCL-2

Temperature dependence of Dk/Df



HC-G0037 CCL

HC-G0024 CCL

Commercially available CCL-1

Commercially available CCL-2

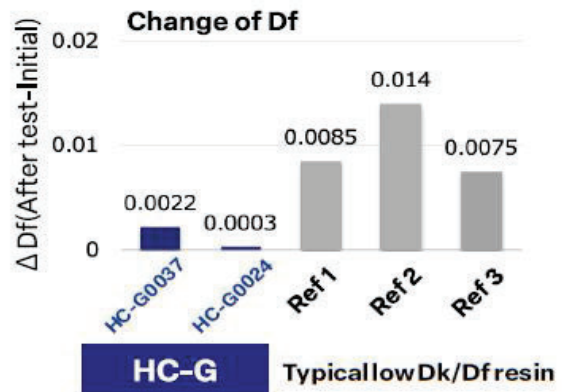
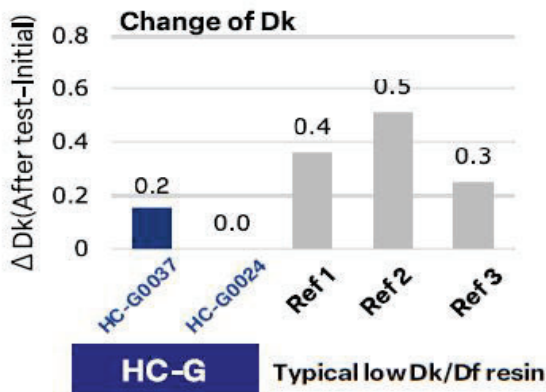
JSR ELPAC™ HC-G series

Low Dk/Df **STPE** (Self-crosslinking Thermosetting Poly**E**ther)

Evaluation examples of reliability

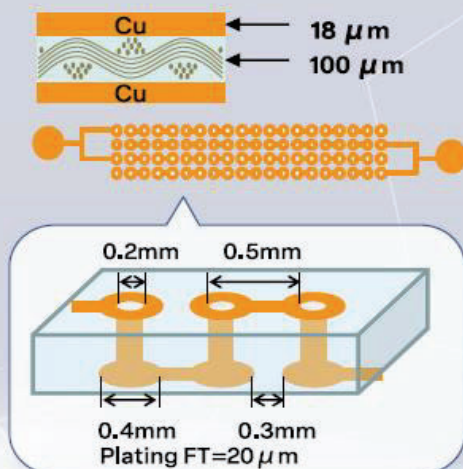
1. Heat resistance of cured film

Condition: 150°C x 500h under air
Change of appearance

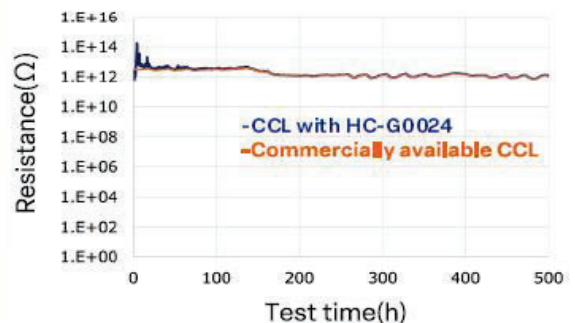


Composition: HC-G polymer / Organic peroxide. Cured at 200°C

2. Reliability of CCL with HC-G polymer



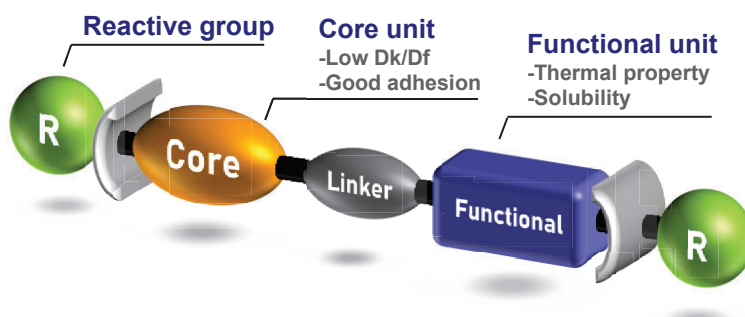
Condition: 85 °C, 85 %RH, DC 100V



JSR ELPAC™ HC-G series

Higher molecular weight type

Design Concept



		HC-G0043	HC-G0044
Feature		Ultra low Df Good adhesion	Ultra low Df Excellent adhesion
Structure	Core + Functional	B'	B''
	R	Radical-curable	Radical-curable
	Molecular weight	Middle	High
Product	Non-volatile (%)	45-55	40-50
	Solvent(%)	Toluene 55-45	Toluene 60-50
	Viscosity(mPa s @25°C)	500-9,000	600-9,000
Properties Composition Initiator 0.5phr	Dk/Df @10GHz	2.6/0.0008	2.6/0.0008
	Tg (°C, DMA)	216	224
	T _d ⁵ (°C)	420	428
	Peel strength (N/mm)	0.7	1.0

Curing Condition: 200°C x 2h, under N₂.